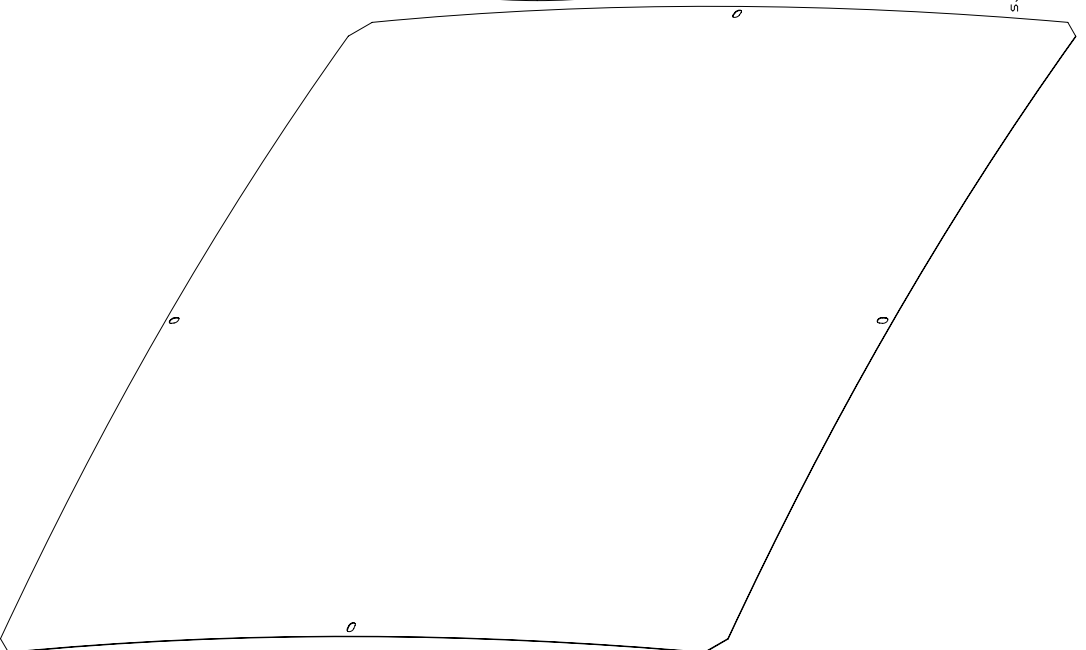




T. H. E.		DEPT OF ASTRONOMY	
OHIO		DESCRIPTION	
STATE		MODS Spectrograph	
UNIVERSITY		Multi-Slit Mask	
MATERIAL	FINISH	GENERAL TOLERANCES	
150 micron	✓	DECIMALS	ANGULAR
Nickel electroform		.XX +/-. 01mm	+/- 0° 30'
DESIGNED BY TPD	DATE 10/20/06	XX +/- .005mm	
DRAWN BY	DATE	PART NAME	
APPROVED BY	DATE	MASK TRIM R1	
SCALE:		UNLESS OTHERWISE NOTED ALL DIMENSIONS IN .001"	